The 8th International Conference on Microelectronics and Plasma Technology | The 9th International Symposium on Functional Materials

## Joint International Conference on The 8th ICMAP & The 9th ISFM

January 17-20, 2021 | Online Conference

[MB2] 2D Materials and Their Application to Nano/Micro Devices IV	
Date / Time	January 18 (Mon.), 2021 / 14:10-15:40
Place	Channel B
Session Chair(s)	Tae Sung Kim (Sungkyunkwan Univ., Korea)
	Joo Hoon Kang (Sungkyunkwan Univ., Korea)

[MB2-1] Invited 14:10-14:40

Energy Applications of 2D TMD FETs and Diodes Fabricated Using Plasma Processes

Seongil Im

Yonsei Univ., Korea

[MB2-2] 14:40-15:00

Precursor-Assisted Chemical Welding for High-Performance Broadband Photodetectors

Jihyun Kim<sup>1</sup>, Seongchan Kim<sup>1</sup>, Yunseong Cho<sup>1</sup>, Minseok Choi<sup>1</sup>, Suho Jung<sup>1</sup>, Jeongho Cho<sup>2</sup>, Dongmok Whang<sup>1</sup>, and Joohoon Kang<sup>1</sup>

<sup>1</sup>Sungkyunkwan Univ., Korea, <sup>2</sup>Yonsei Univ., Korea

[MB2-3] 15:00-15:20

## Graphene Edge Contact Devices Fabricated via Plasma Etching

Sungwon Lee, Inyong Moon, Tien Dat Ngo, Myeongjin Lee, Kwangro Lee, Hoseong Shin, and Won Jong Yoo

Sungkyunkwan Univ., Korea

[MB2-4] 15:20-15:40

Modification of MoS<sub>2</sub> Surface by Inductively Coupled Remote Plasma

Ji Eun Kang, Ki Hyun Kim, You Jin Ji, and Geun Young Yeom Sungkyunkwan Univ., Korea